# Beam Instrumentation Experience at ATF

#### Yosuke Honda ATF international collaboration

2007/Jan./31 APAC07, Indore

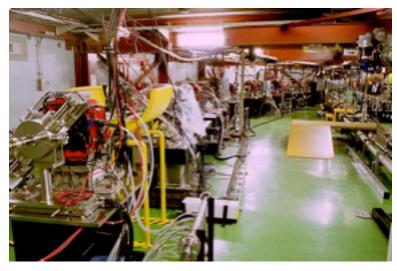
- Introduction
- Beam position monitors
- Beam size monitors
- Beam control

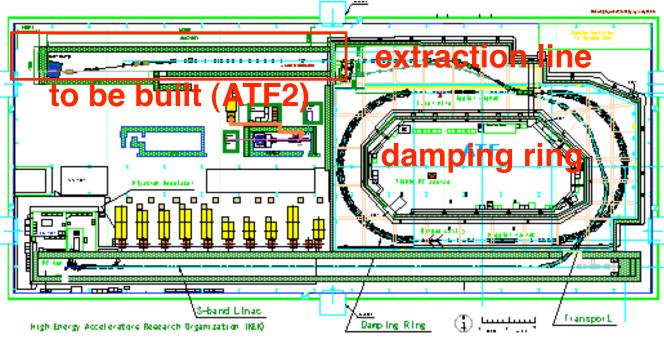
#### Introduction

#### ATF

- Accelerator Test Facility for LC
  - low-emittance Damping Ring
  - damped beam extraction line
- parameters
  - energy: 1.3GeV, DR circumference: 140m
  - rep. rate: 1.56Hz, bunch charge: 10^10e/bunch
  - emittance: 1nm rad (x), 10pm rad (y)
  - typical beam size: 100um(x), 10um(y)
- an unique facility to produce ILC-spec. beam

#### extraction line

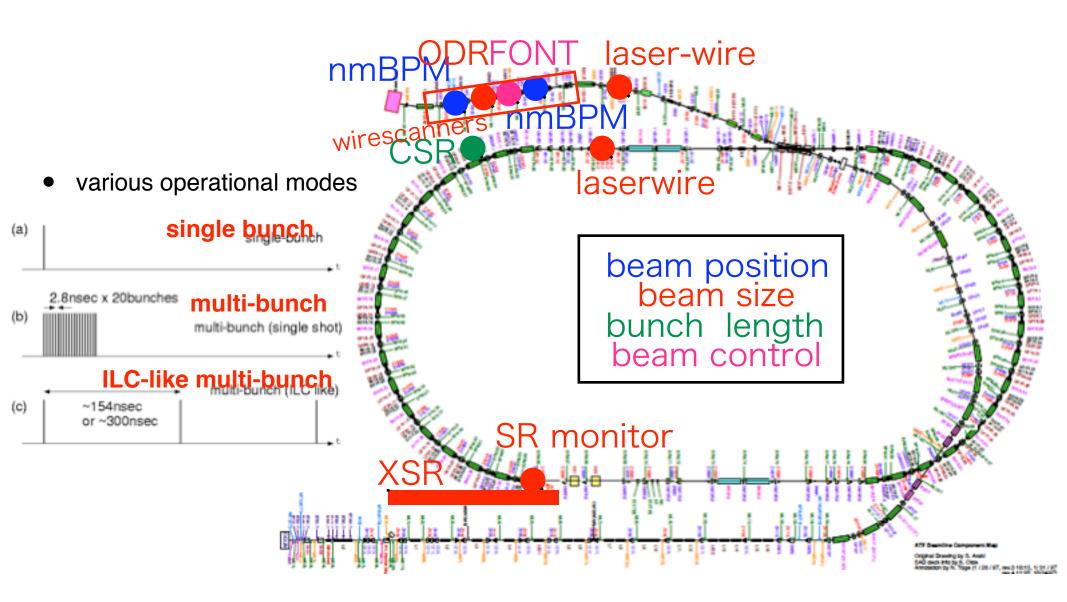




#### damping ring



#### Instrumentation R&D at ATF

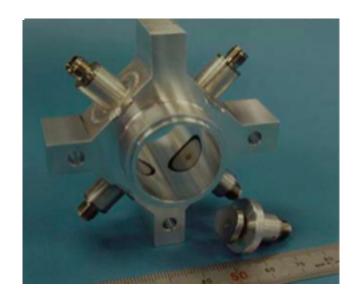


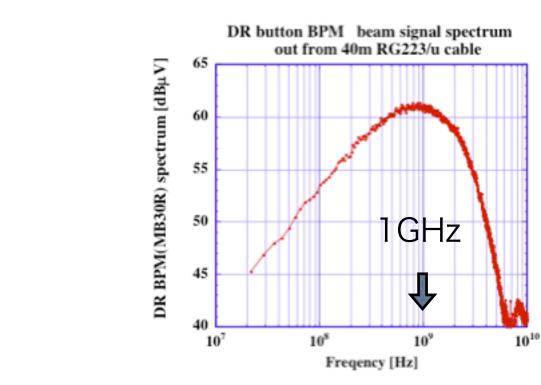
#### **Beam Position Monitors**

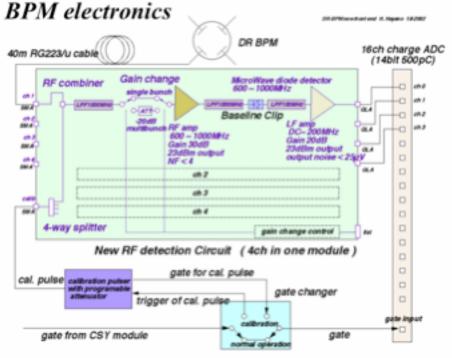
- pick-up BPM
- cavity BPM

### Pick-up BPM

- BPM for usual beam operation
  - shot-by-shot orbit measurement
- BPMs
  - 96 buttun BPMs in DR
  - strip-line BPMs in linac and ext.line
  - beam duct diameter is 24mm
  - spectrum peak is at 1GHz (end of the cable)
- electronics
  - wide band detection (0.6~1GHz) , diode clipping





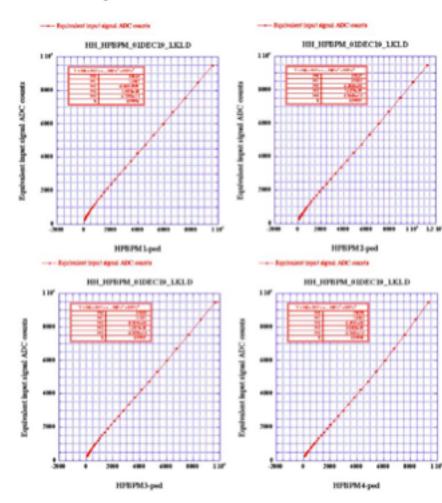


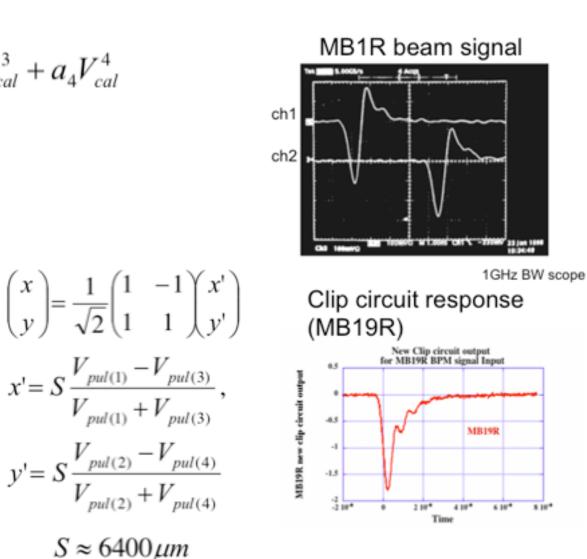
Electronics: 600MHz - 1GHz BW, base line clip & low noise LF amp

# Pick-up BPM

- calibration of the electronics
  - using a dummy pulse
  - non-liniarity correction with a polynomial function

$$V_{pul} = a_0 + a_1 V_{cal} + a_2 V_{cal}^2 + a_3 V_{cal}^3 + a_4 V_{cal}^4$$



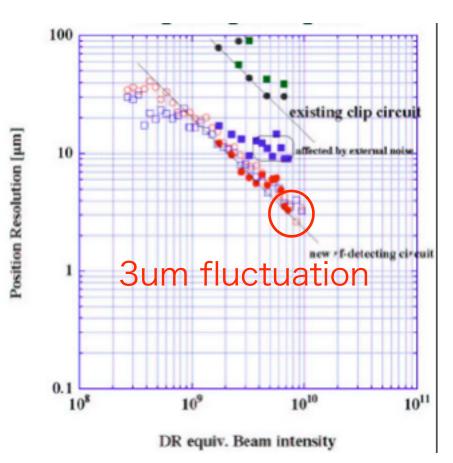


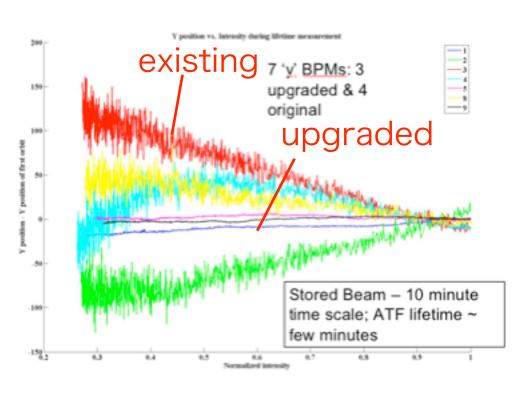
 $S \approx 6400 \,\mu m$ 

 $y' = S \frac{V_{pul(2)} - V_{pul(4)}}{V_{pul(2)} + V_{pul(4)}}$ 

# Pick-up BPM

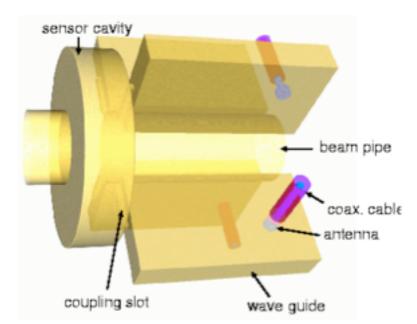
- performance
  - resolution: 3um at 10^10e/bunch
  - intensity dependence: +-150um
- upgrade plan
  - narrow-band system with digital recording
    - 100nm resolution, 500nm accuracy expected

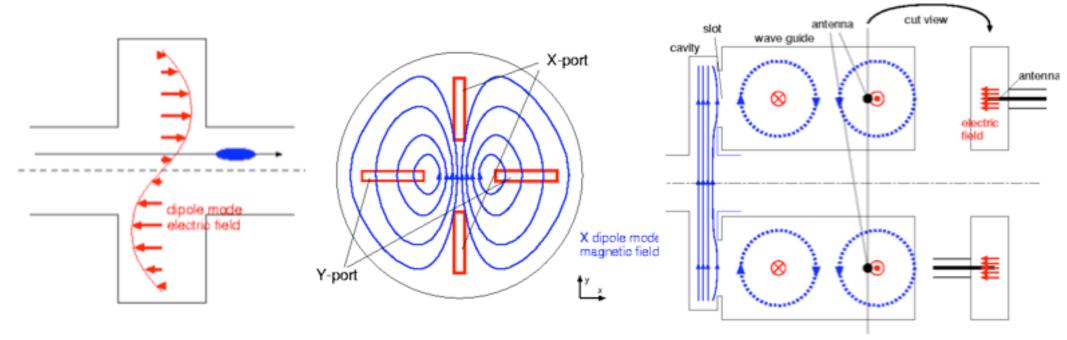




# Cavity BPM

- Cavity BPM
  - strong signal, possible to reach nm resolution
  - mechanical rigidity, electrical center stability
- Several types of cavity BPMs are tested in ATF ext.line.
  - basic design is same for all type
  - C-band is optimal for ATF beam (bunch length)

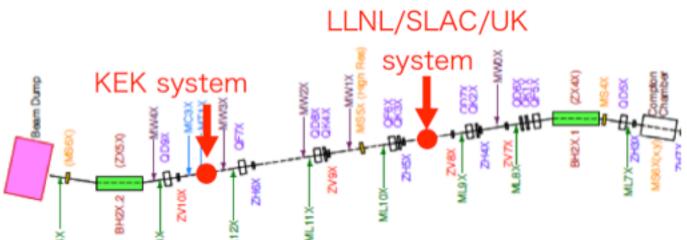


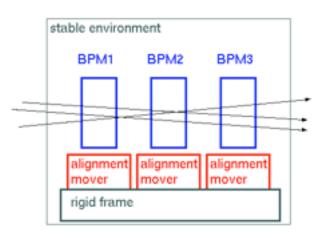


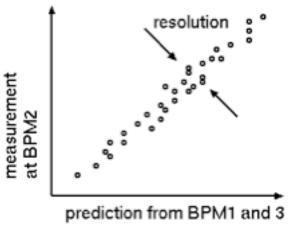
#### nm-resolution BPM

- Test bed for very high resolution BPM
  - triplet of BPM supported by a rigid frame
  - mover system to align within 10um
- Two sets of system are installed in the ext.line
  - BINP/LLNL/SLAC/UK group (upstream)
  - KEK group (downstream)



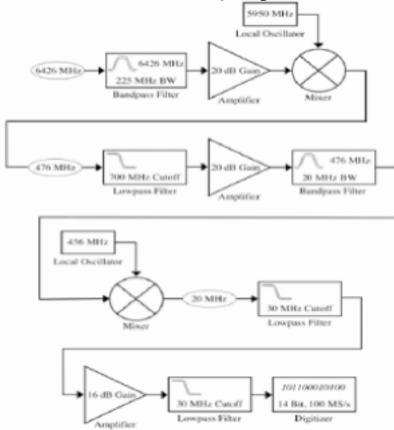


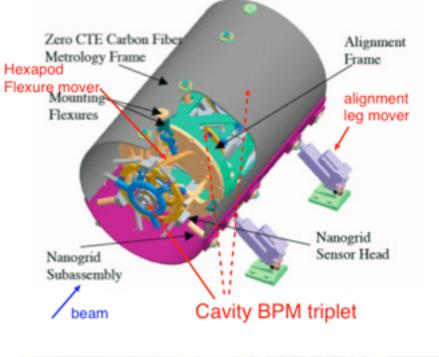


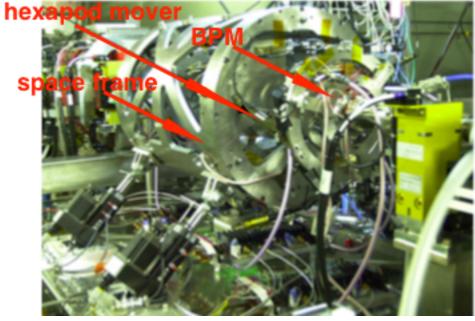


# nm-resolution BPM (upstream)

- space frame
  - alignment mover for overall frame
  - 6D hexapod flexure mover for each BPM
- rigid-body monitoring system
  - laser sensor on metrology frame
  - <5nm stability
- digital wf recording
  - 6.43GHz->20MHz, two-stage down-mix
  - 100MHz, 14-bit sampling for 20MHz signal

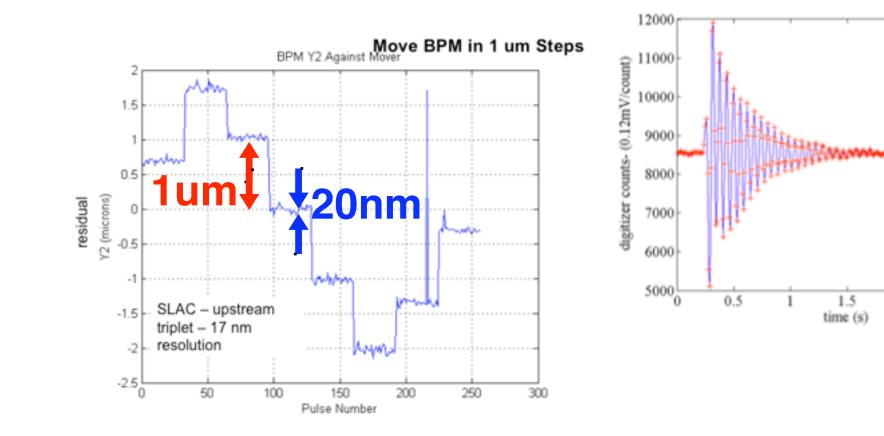






### nm-resolution BPM (upstream)

- Analysis of the waveform
  - fitting with decaying sinusoidal
  - digital down conversion (BW 2.5MHz)
- calibration
  - convert I-Q phase to position-angle
  - mover with known step
- 17nm resolution was proved



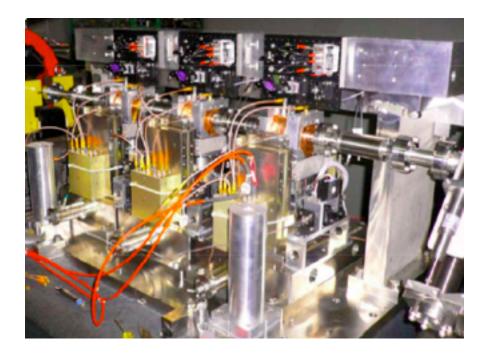
2.5

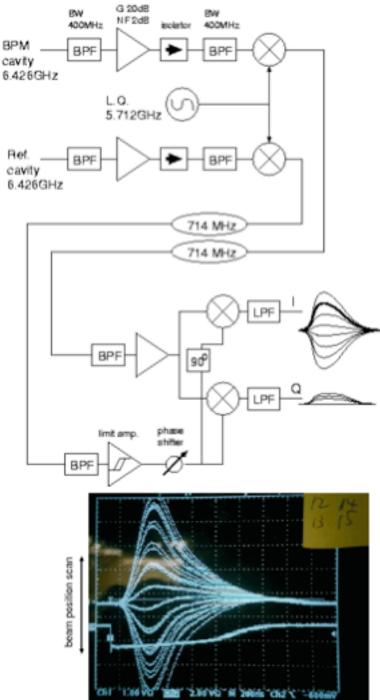
x 10

2

# nm-resolution BPM (downstream)

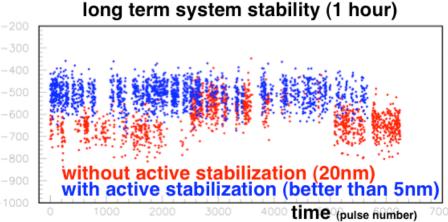
- frame
  - piezo mover with an active stabilization
  - laser interferometer sentor
- electronics
  - analogue processing (BW 1MHz)
  - phase detection with a reference cavity

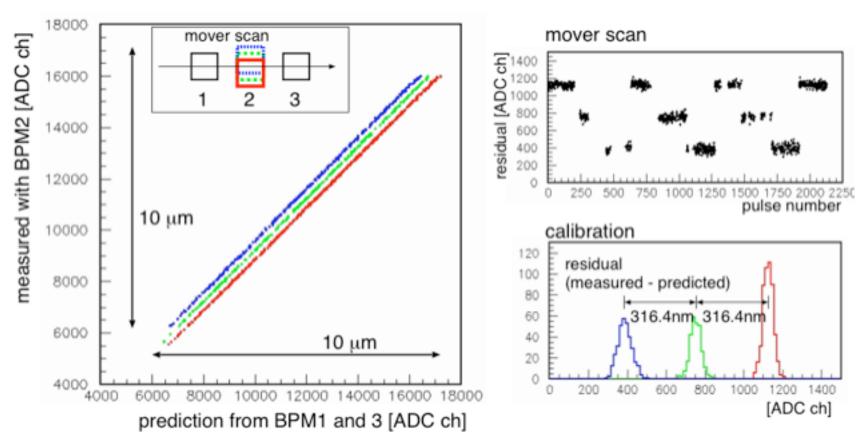




# nm-resolution BPM (downstream)

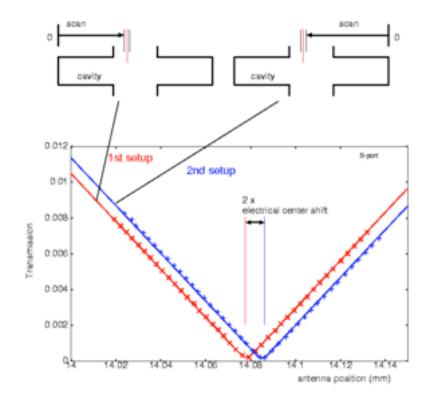
- - calibration
    - move one of the BPM with known amount sidual (prediction-measurement) RMS 21.2nm (17.3nm resolution) 0.4nC beam charge consistent with the calculation
  - residual (prediction-measurement)
- System stability
  - shows improvement with the active stabilization



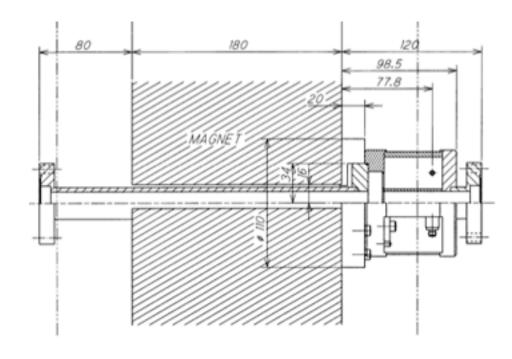


# ATF2 cavity BPM

- main monitor for ATF2 beam line
  - 100nm resolution, 2um stability
  - attached on every quadrupole
- fabrication in PAL (talk by JY-Huang)
- performance tests at bench
  - electrical center accuracy < 5um
  - isolation of x and y modes < -40dB
    - post-fabrication tuning







# ATF2 cavity BPM

Is/bunch) [volt]

Peak voltage at the output of BPM nalized for 10^10 electrons/bunch)

(normalized for

0.9

0.8

0.7

0.6

0.5

0.4

0.3

0.2

0.1

-4000

-3000

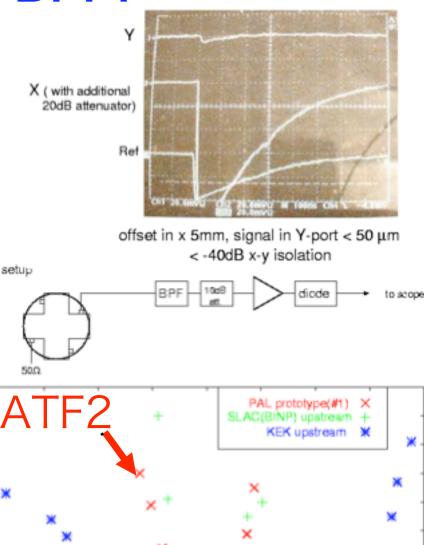
-2000

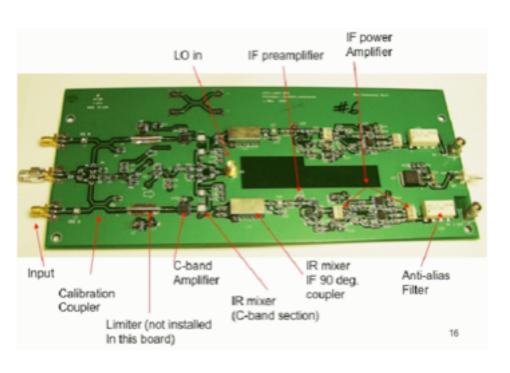
-1000

0

1000

- Beam tests
  - signal strength was confirmed
  - x-y isolation was confirmed
- electronics
  - PCB version of down converter
  - various monitors are implemented
    - temperature, gain calibration etc.





beam position at the Cavities [um]

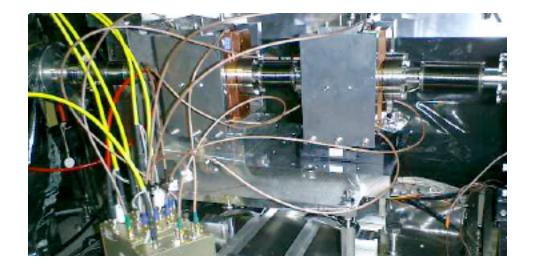
3000

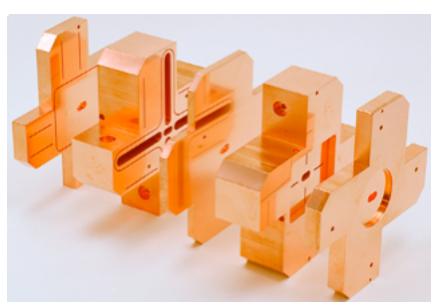
4000

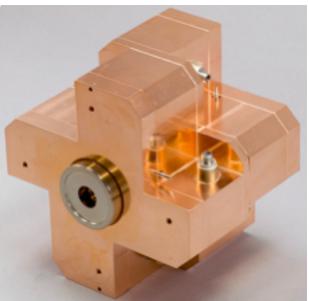
2000

# ATF2 IP-BPM

- purpose
  - beam stability measurement at ATF2 virtual IP
  - required resolution is 2nm
- IP optics (strongly focused)
  - angular jitter
  - x jitter is larger than y jitter
- special design
  - thin gap cavity to reduce angle signal
  - rectangular cavity to separate x and y modes
  - high coupling for stronger signal
- beam tests started Nov.2006
  - position sensitivity was confirmed
  - angular sensitivity was confirmed





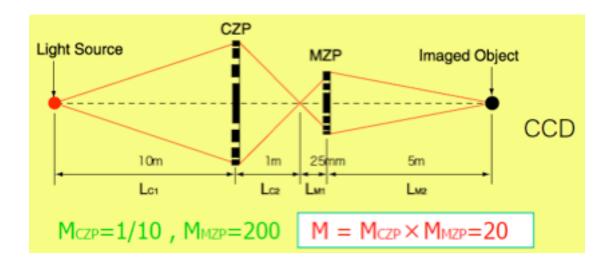


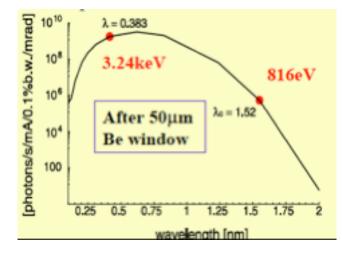
#### **Beam Size Monitors**

- Imaging type
- Scanning type

# X-Ray SR Imaging Monitor

- direct 2D imagning of beam spot
  - real-time monitor
- SR Imaging
  - diffraction limit
    - visible light: ~10um
    - X-ray (3.24keV): improves to 0.25um
      - 3.24keV is the highest flux in the case of ATF ring including attenuation at the window
  - optical component: FZP
    - spatial resolution is determined by the most outer ring
    - two lens optics to make the system compact
    - designed system resolution: 1.7um



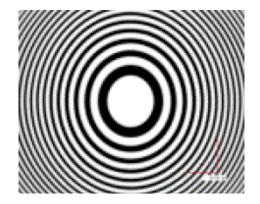


 $r_n = \sqrt{nf\lambda}$ 

 $\lambda$ : wave length, f: focal kength

$$\delta = 1.22 \times \Delta r_n$$

 $\Delta r_n$ : width of the most outer zone



### X-Ray SR system

• Source point: final bend in the arc section of the ring

bending magnet

CZF

1025mm

on X-Y stage

- window -> monochrometor -> CZP -> MZP -> CCD , all in vacuum
- X-ray line length: 3.4m + 12.6m

source point

MZP

2nd |

on X-Y-Z stage

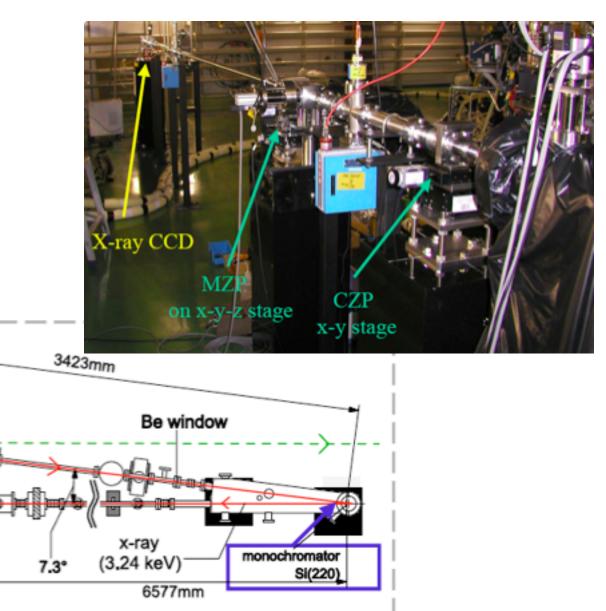
- alignment movers for FZPs
  - search the best focus
- 1msec time shutter

electron

orbit

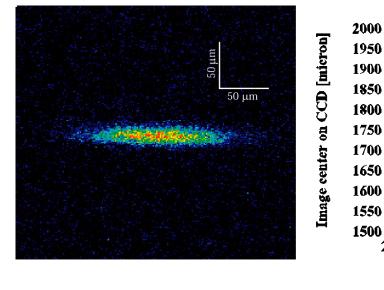
x-ray CCD

5000mm

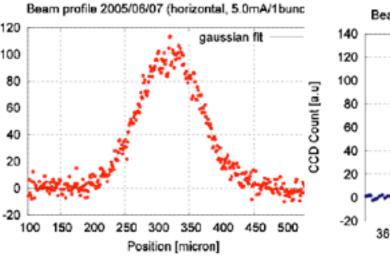


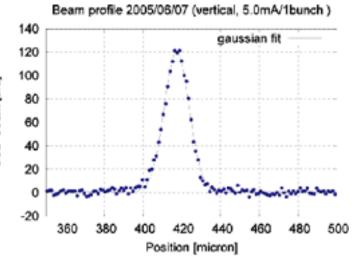
# X-Ray SR Imaging Monitor

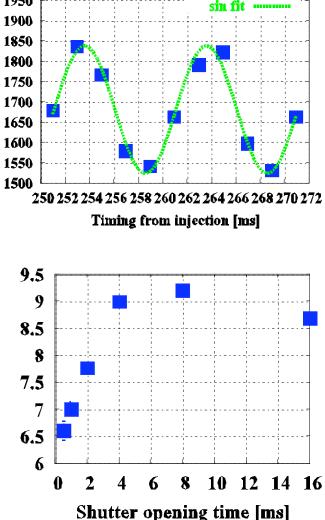
- position jitter of the image was suppressed with the fast time shutter (1msec)
- measured beam size
  - x size: 48.2um
  - y size: 6.4um



beam size [micron]



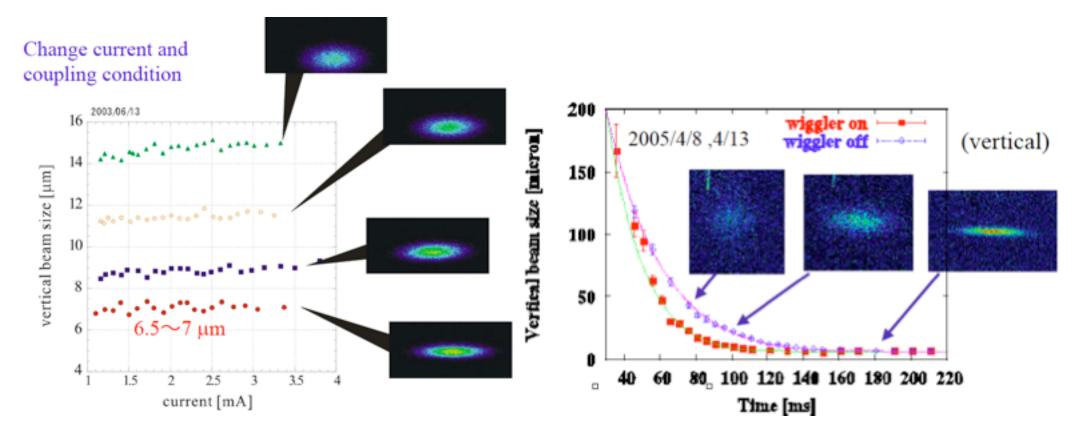




data 🔤

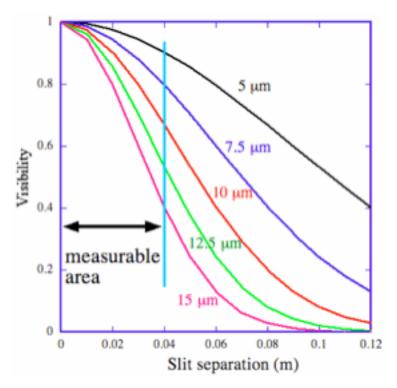
# X-Ray SR Imaging Monitor

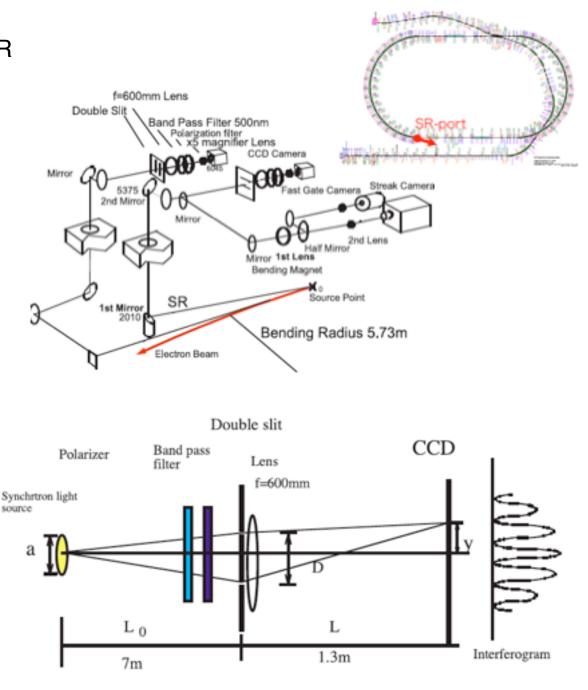
- Check emittance tuning of the DR
- Time resolution is faster than damping time
  - observation of transverse damping



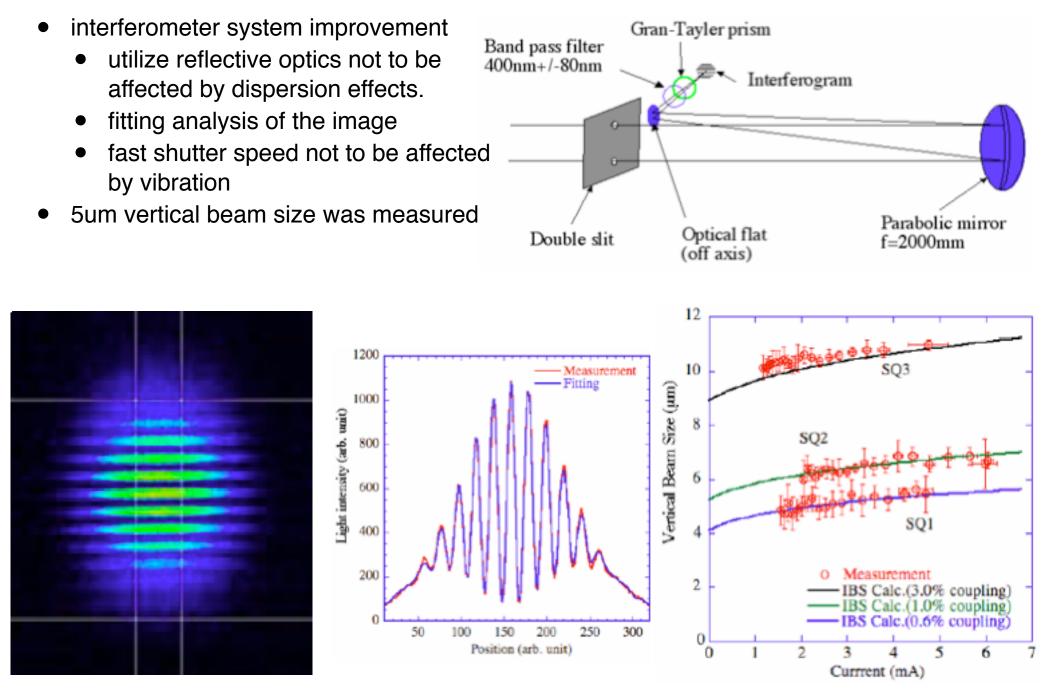
### SR Interferometer

- measure the spot size of the SR source from spatial coherence of SR
  - double-slit interferometer
  - < diffraction limit of imaging
- shot-by-shot measurement
- limit
  - slit separation
  - light intensity (filter band width)
  - mechanical vibration
  - setup alignment



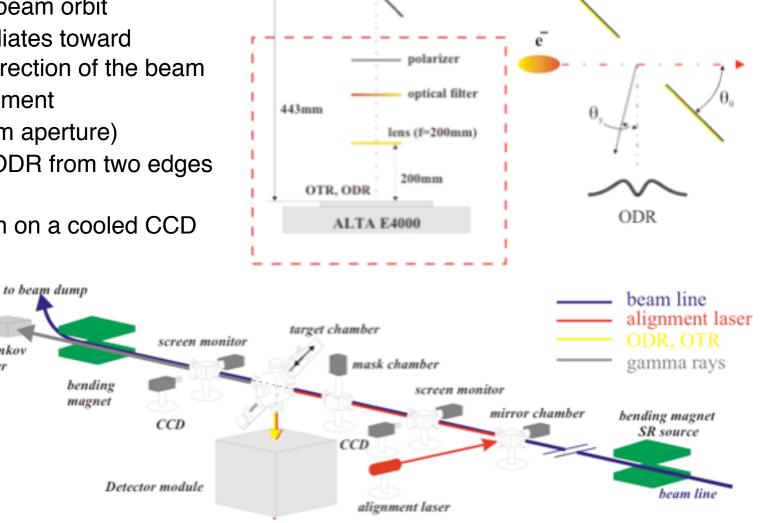


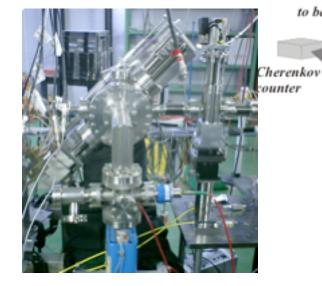
# SR Interferometer



### **ODR** beam size monitor

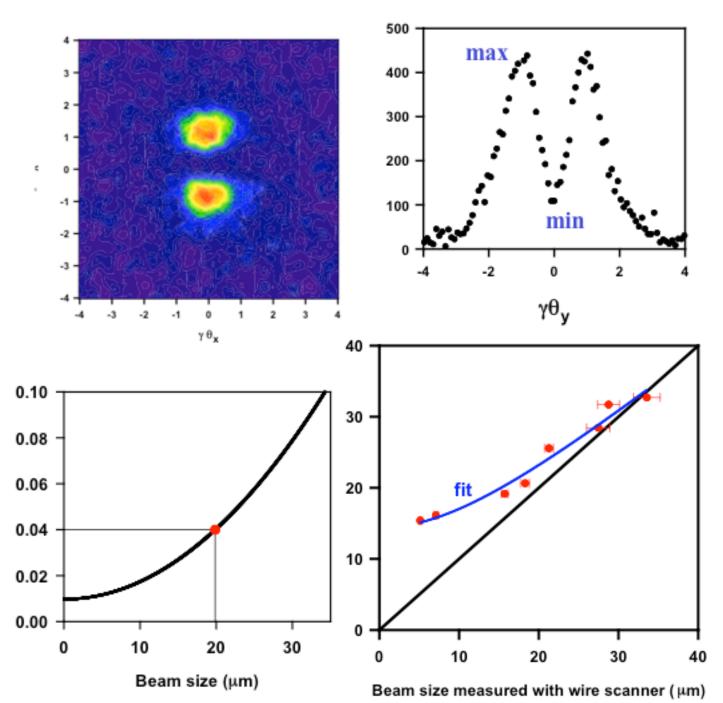
- Single-shot beam size measurement in the extraction line
- **Optical Diffraction Radiation** 
  - visible radiation from a conductive object near the beam orbit
  - 45deg. plate radiates toward parpendicular direction of the beam
- beam size measurement
  - slit target (230um aperture)
  - interference of ODR from two edges of the target
  - two-peak pattern on a cooled CCD





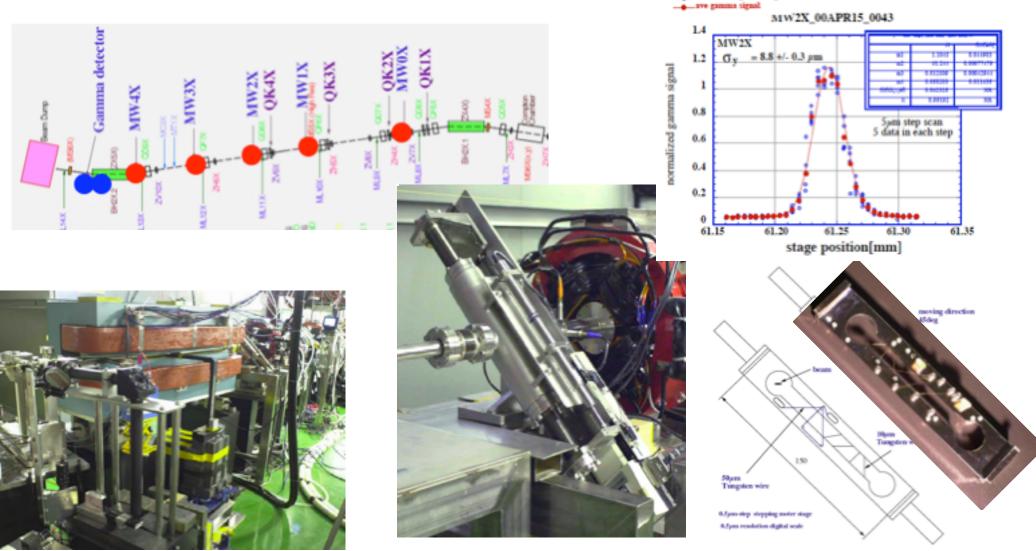
#### **ODR** beam size monitor

- min/max is a good measure to tell the beam size
- performance test
  - comparison with wire-scanner
  - measurable as small as 15um
- setting up
  - align the beam position to the slit center
  - reduce SR background
  - quality of the target is important



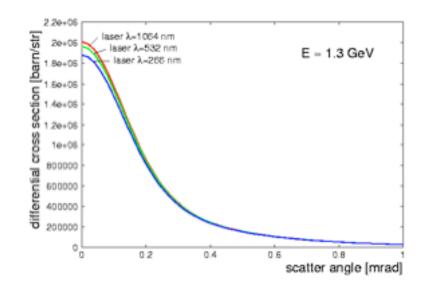
# Wire scanner system

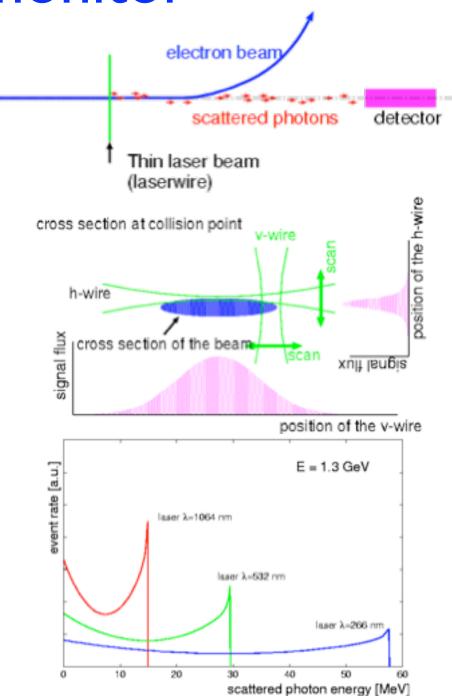
- 5wire scanners are located in the straight section (dispersion less) of the ext.line
  - tungsten wire of 10um diameter
  - x,y,45deg., 10deg. direction wires are mounted in a scanning stage
- air cherenkov detector
  - two types of sensor: PMT, and APD (multi-bunch with 2.8nsec spacing)



#### Laserwire monitor

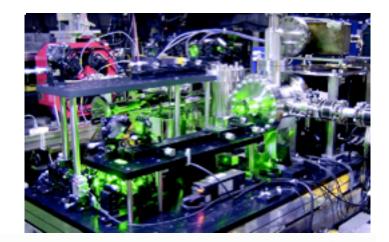
- Replace target of wire-scanner with a focused laser beam
  - non-invasive measurement
  - not damaged by beam
- interaction
  - Compton scattering
  - 28MeV scattered photon (ATF case)
- laser
  - high power and focused
- two different systems
  - cw laser with a build-up cavity (ring)
  - pulsed laser with a strong focus (ext.line)

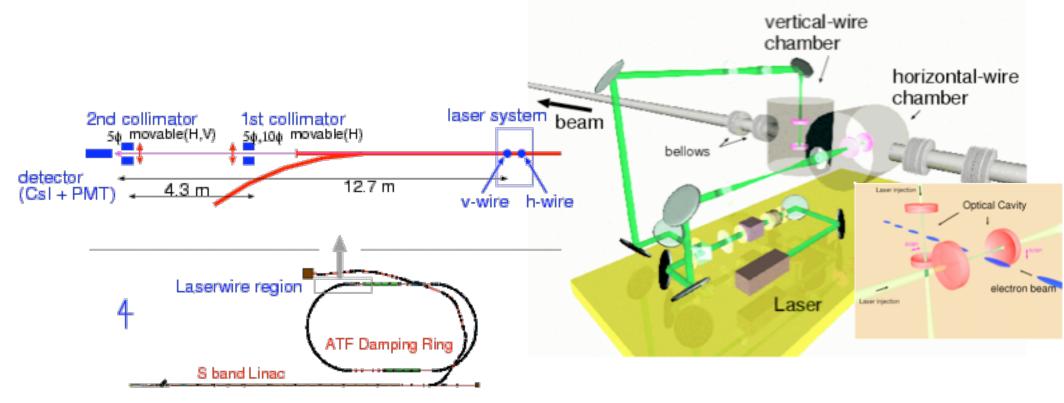




# Laserwire monitor (DR)

- Laser system
  - cw laser, optical components
  - build-up optical cavity
- scanning mover
  - whole laser system is on the mover table
- detector
  - Csl counter, fast enough to separate bunches

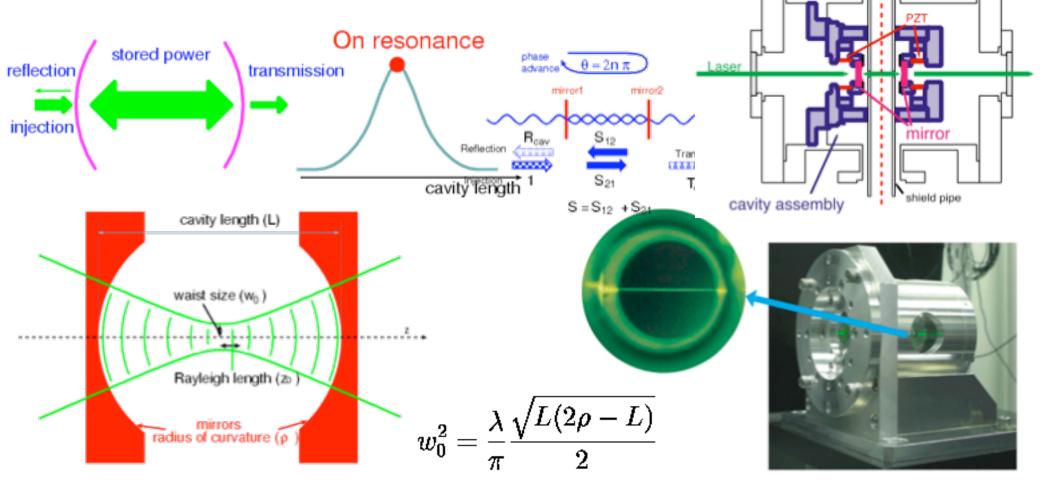




# Laserwire monitor (DR)

vacuum chambe

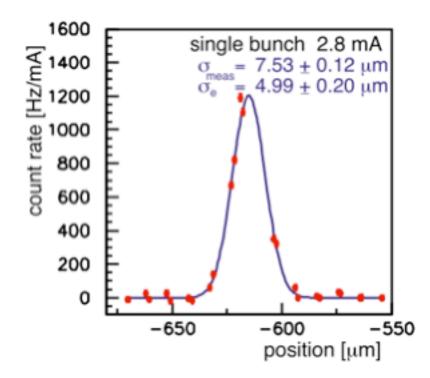
- Optical cavity
  - high effective power
    - high finesse build-up cavity, x1000 power enhancement
    - feedback control to keep resonance
  - small spot size
    - nearly concentric configuration, 5.6um size
    - stable realization of fixed spot size

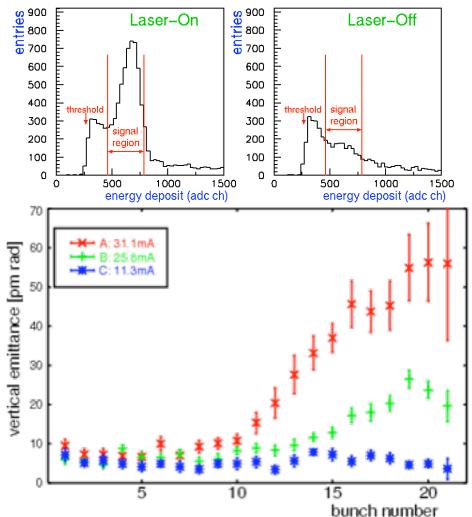


### Laserwire monitor (DR)

- counting detection
  - measure laser-on and off simultaneously
- subtract contribution of the laser size from the measured width
- multi-bunch measurement
  - time resolution of the detector is fast enough to identify 2.8nsec spacing bunches

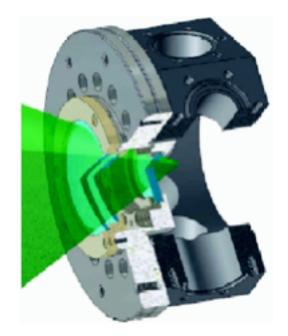
$$\sigma_e = \sqrt{\sigma_{meas}^2 - \sigma_{lw}^2}$$

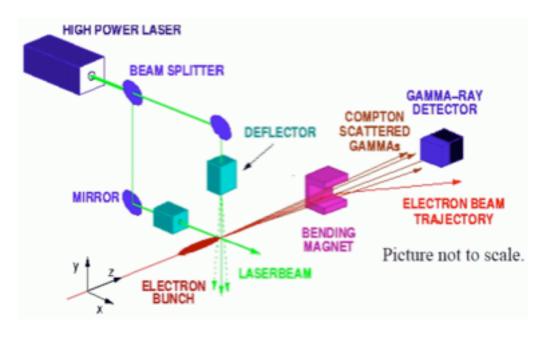


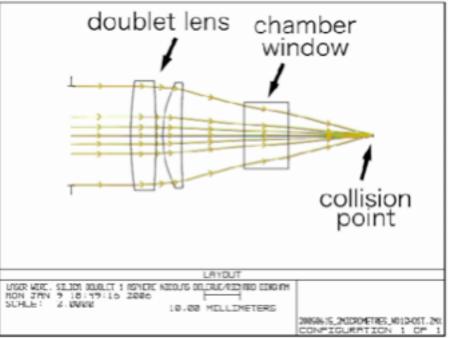


#### Laser wire monitor (ext.line)

- single path beam line
  - higher laser power is necessary
  - high power pulsed laser (100psec)
- special focusing lens
  - F#2 lens (1um spot) in preparation
  - test with F#10 lens at present







# Laser wire monitor (ext.line)

detector

Extraction line coordinate system

45deg.screen

7 A

ODA light

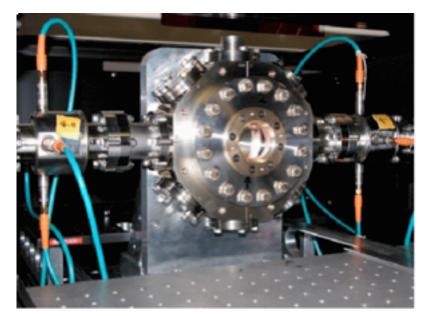
- aerogel cherenkov counter
- test at the ext.line
  - establish laser-beam collision
    - timing adjustment
- laser focusing quality

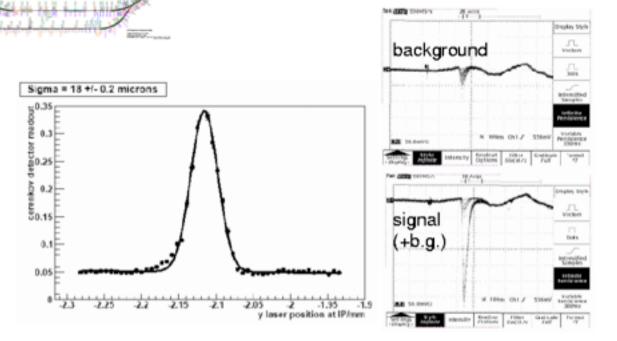
Overlap screen

Electron beam

e-beam

Scréen





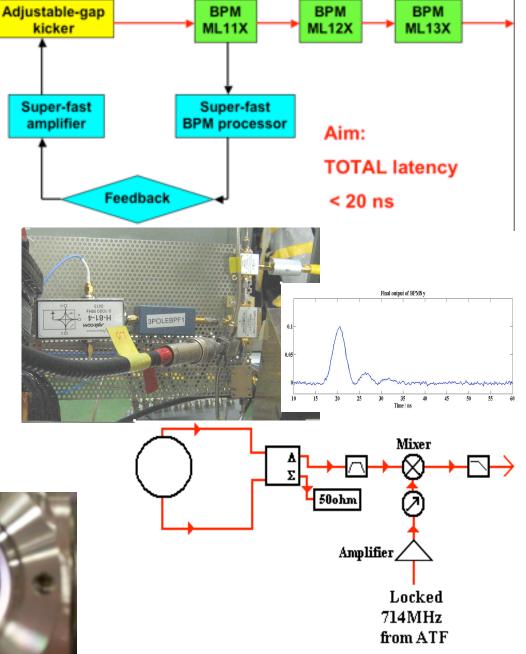
#### Beam Control

• beam position feedback stabilization for multi-bunch

# FONT3

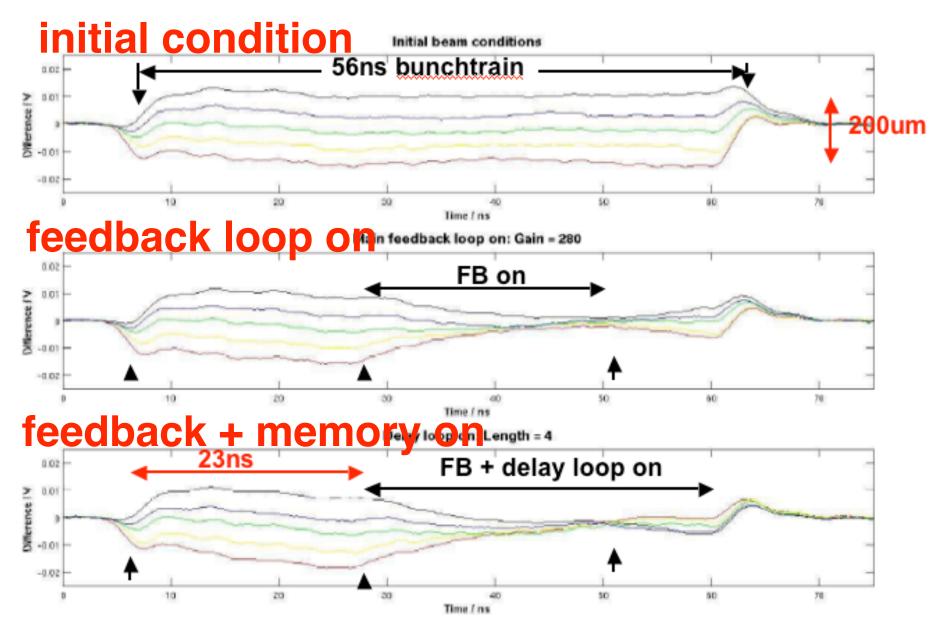
- beam position stabilization
  - feedback within a train
  - multi-bunch 2.8nsec x20
- system
  - adjustable-gap strip-line kicker
  - strip-line bpm with a fast analogue processor (5um resolution)



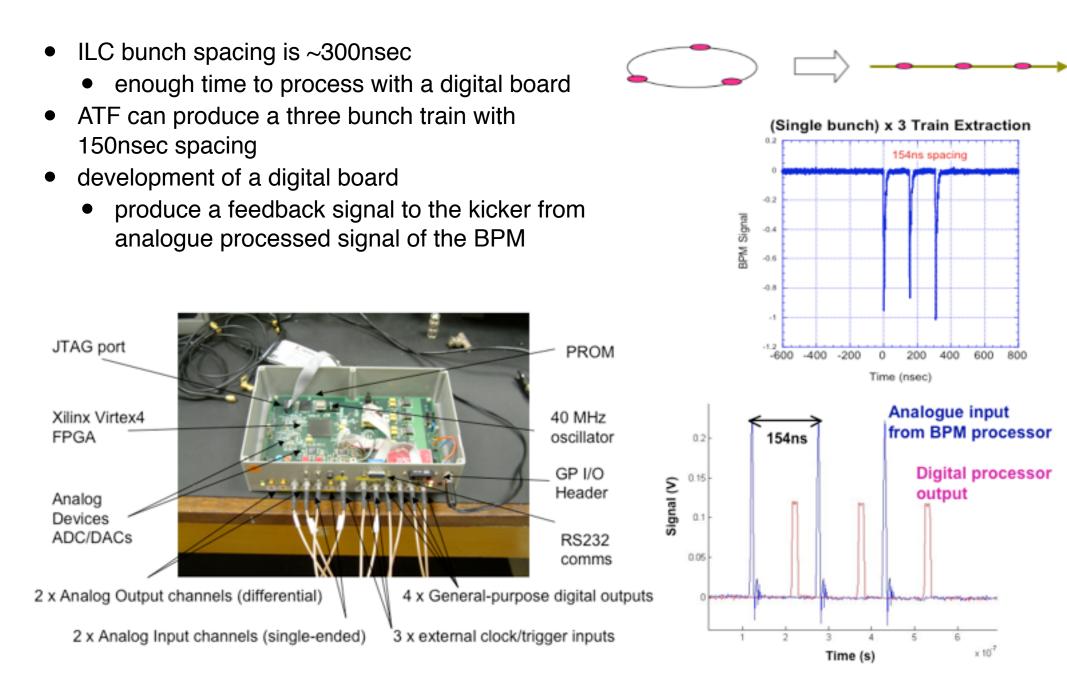


# FONT3

proved fast feedback



# FONT4



# summary

• There are many beam monitor R&D activities in ATF